

GUJARAT TECHNOLOGICAL UNIVERSITY

BE - SEMESTER- V (New) EXAMINATION - WINTER 2019

Subject Code: 2153901 Date: 25/1			/11/2019
Sub	ject N	Name: Fabrication of Nano- devices	
Time: 10:30 AM TO 01:00 PM Total Mar			arks: 70
Instr	uctions		
	2.	Attempt all questions. Make suitable assumptions wherever necessary. Figures to the right indicate full marks.	MARKS
Q.1	(a)	Explain Core-Shell Structure.	03
	(b)	Describe Atom Lithography.	04
	(c)	Define Quantum Structures. Explain Its Size and Dimensionality Effect.	07
Q.2	(a)	Define Gas Sensor.	03
	(b)	Describe Graphene and Fullerene.	04
	(c)	Define Photonic Crystal and explain Photonic band Gap devices with Application.	07
		OR	
0.3	(c)	Describe Protein-Based Biosensor	07
Q.3	(a)	Explain Lithography. Mention Different types of Lithography.	03
	(b)	Explain Different type of Gas Sensor Briefly.	04
	(c)	Explain X-ray Lithography with Appropriate Diagram. OR	07
Q.3	(a)	Describe Schottky Diodes and Schottky Barriers.	03
	(b)	Define DNA Based Biosensor.	04
	(c)	Write down full form of MOSFET, explain it briefly with Types(Diagram)	07
Q.4	(a)	Explain the Concept of Photochemical Molecular Devices.	03
	(b)	Define Nanorods, Nanowire, Nanofibres and Nanotubes.	04
	(c)	What are Nanocomputers? Explain its Fabrication Methods and Types.	07
0.4	()	OR OR	0.2
Q.4	(a)	Define Antibody and Antigens. Describe Application by Function of Gas Sensors.	03 04
	(b) (c)	Explain the Concept of Single Electron Tunneling.	07
0.5	(a)	Mention Any Five Single Electron Devices.	03
Q.5	(b)	Describe Optical Fibers for Nanodevices.	03
	(c)	Define Resonant Tunneling and hence explain Resonant tunneling	07
	(-)	Diode, Resonant Tunneling Transistor.	
		OR	
Q.5	(a)	Explain Nano Robotics and Nano Manipulation.	03
	(b)	Define Carbon Nanotube based Logic Gates.	04

(c) Write a short note on Ion Lithography.

07